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Full-wave modelling of terahertz frequency plasmons in two-dimensional electron systems

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Abstract

While models of terahertz frequency plasmons in 2D electron systems are usually developed by reducing the number of spatial dimensions, fully 3D models may be needed for the design and analysis of realistic structures. Using full-wave electromagnetic simulations, we have analysed the plasmons and magnetoplasmons observed in two recent experiments. Here, we demonstrate agreement between the theoretical and the experimental results, and discuss further device characteristics such as plasmon transmission, reflection, absorption, and field distributions. We then compare the 3D full-wave simulations with a 2D model. Finally, we discuss approaches for increasing signal transmission and reducing reflection, with direct relevance for improving future experiments.

Keywords: 2D electron systems, plasmon, terahertz, waveguides

1. Introduction

Two-dimensional electron systems (2DESs) are capable of supporting plasmons, which are slow electromagnetic waves caused by collective electron motion. In 2DESs formed in III-V semiconductor heterostructures, plasmon frequencies typically lie in the microwave to terahertz frequency ranges. Terahertz plasmons are particularly attractive as they could be exploited in a range of practical devices, and notably, emitters and detectors.

Ever since the pioneering works of Dyakonov and Shur [1, 2], one of the most commonly studied geometry for terahertz plasmon emitters and detectors is that based on the field-effect transistor (figure 1(a)). A 2DES is terminated by two

ohmic contacts, which allows application and detection of a dc voltage as well as the coupling-in and -out of terahertz waves [3–7]. Above the 2DES is a gate, which controls the electron density in the 2DES, and is frequently used for coupling into the free-space radiation. Variations of this basic structure have also been made, such double-grating-gate, meander-gate, and comb-gate devices [8–12].

Theoretical studies of such devices have been made predominantly with two-dimensional (2D) models [1, 14–24], in which the devices are assumed to be infinitely long in the y -direction (figure 1(a)). Three-dimensional (3D) models, however, may be needed to describe realistic devices, especially when agreement with experiment is sought. As an example, figures 1(b) and (c) show, respectively, a micrograph and a sketch of the experimental device used by Wu *et al* [7, 13]. Several features that cannot be taken into account by a 2D model stand out. First, the width of the 2DES ($25\ \mu\text{m}$ in the y -direction) is smaller than its length ($73\ \mu\text{m}$ in the

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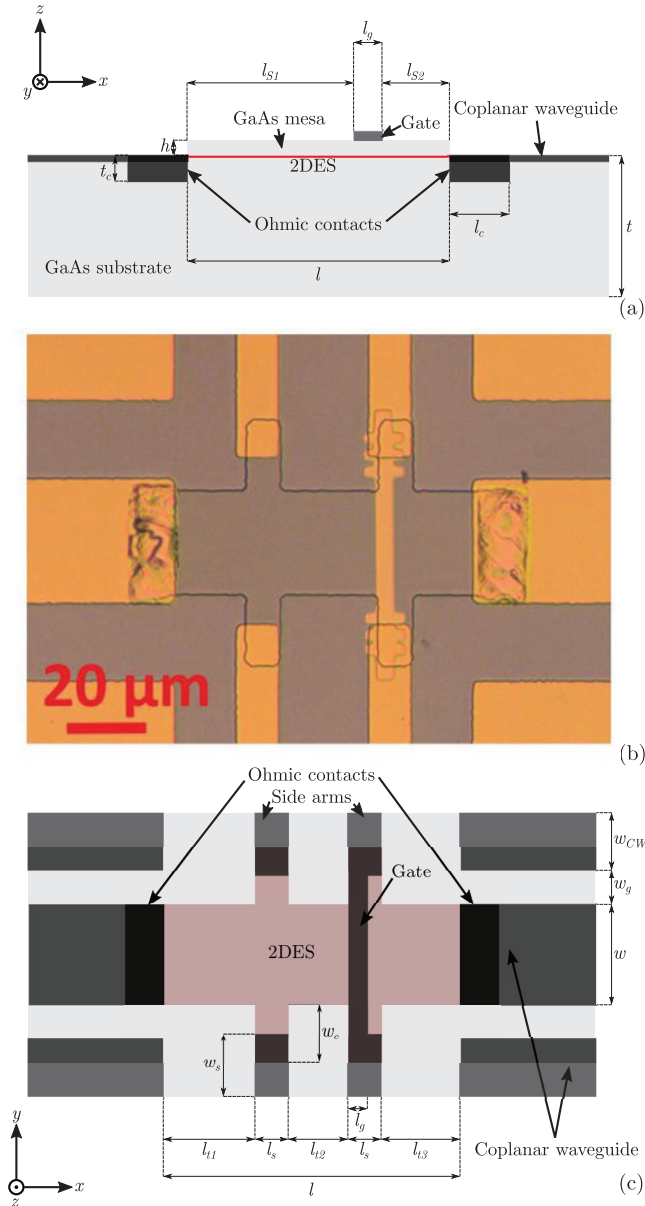


Figure 1. (a) Schematic side view of a 2DES device used in the experiments by Wu *et al* [7, 13]. The device geometry is inspired by the field-effect transistor. (b) Micrograph and (c) schematic top view of the device. The complex device geometry requires 3D modelling. Reproduced from [7]. [CC BY 4.0](https://creativecommons.org/licenses/by/4.0/).

x -direction). Second, the 2DES is connected at both ends to a coplanar waveguide. Third, the 2DES has a non-rectangular shape with four short stubs.

Full-wave numerical simulations are a natural choice for analysis of such structures. In this paper, we will:

1. compare a full-wave 3D electromagnetic model with the experiments by Wu *et al* [7] on plasmon- (section 3) and magneto-plasmon transmission (section 4);
2. analyse the experimental devices beyond the available experimental data (section 3);
3. compare the 3D model with a 2D model based on mode-matching (sections 3 and 4);
4. design and model a device geometry with improved characteristics (section 5).

Table 1. Dimensions used in simulations (see figure 1).

2DES length, l	$73 \mu\text{m}$
2DES width/width of centre conductor, w	$73 \mu\text{m}$
2DES depth/mesa height, h	75 nm
Length of first ungated 2DES section, l_{s1}	$48.9 \mu\text{m}$
Length of second ungated 2DES section, l_{s2}	$19.7 \mu\text{m}$
Gate width/length of gated 2DES section, l_g	$4.4 \mu\text{m}$
Stub width, w_s	$24 \mu\text{m}$
Stub length, l_s	$11 \mu\text{m}$
Width of 2DES side extension, w_e	$14 \mu\text{m}$
Separation between left contact and stub, l_{t1}	$16 \mu\text{m}$
Separation between stubs, l_{t2}	$21.9 \mu\text{m}$
Separation between right contact and stub, l_{t3}	$13.1 \mu\text{m}$
Coplanar waveguide gap, w_g	$20 \mu\text{m}$
Width of waveguide ground plane, w_{cw}	$15 \mu\text{m}$
Substrate thickness, t	$50 \mu\text{m}$
Depth of ohmic contact, t_c	1250 nm
Length of ohmic contact, l_c	$12.5 \mu\text{m}$

2. Device structure and modelling considerations

Wu *et al* [7] formed a 2DES in a GaAs/AlGaAs heterostructure grown by molecular beam epitaxy. The depth of the 2DES was $h = 75 \text{ nm}$. We have found that slight variations of the permittivity due to the detailed layer structure had little effect on the simulation results, and we assumed that the substrate material was GaAs, with a relative permittivity of 12.4, see figure 1. The dc electron density in the 2DES was $n_{2D} = 6.5 \times 10^{11} \text{ cm}^{-2}$. The electron scattering time was determined from dc conductivity measurements to be $\tau = 33 \text{ ps}$. The device was formed by etching a rectangular mesa (see table 1 for dimensions). The mesa had four stubs connected to four metal lines, two of which were shorted to form a gate above the 2DES. We have found that including these features into simulations was needed for full agreement with experiments. Two ohmic contacts were formed at both ends of the mesa. A metallic gate was then deposited. An LT-GaAs layer grown on the same substrate allowed Wu *et al* to form two photoconductive switches, one at each side of the device (not shown in figure 1), which were used for excitation and detection of picosecond-duration current pulses. The pulses were both delivered to and extracted from the 2DES using two coplanar waveguides, the centre conductors of which were connected to the ohmic contacts (see figure 1). A negative voltage applied to the gate relative to an ohmic contact depleted the 2DES underneath the gate, and the relationship between the gate voltage and the electron density was found to be

$$V_g = \left(\frac{n_{2D}}{\alpha_1} \right)^{\frac{1}{\gamma}} - \alpha_2, \quad (1)$$

where V_g is in volts, n_{2D} is in cm^{-2} , $\alpha_1 = 5.3813 \times 10^{15} \text{ cm}^{-2}$, $\alpha_2 = 2.601$, and $\gamma = 0.2295$. In the experiments, the voltage typically varied between -0.4 and -2.4 V . Further details about the devices, experimental arrangement, and measurements can be found in [7, 13].

When describing semiconductor plasmons theoretically, one has to choose how to model electron dynamics (both in

the 2DES and at the junctions) and the electromagnetic fields. This paper uses the standard model based on Euler's hydrodynamic equation of motion [1] that, in the absence of static magnetic fields, leads to an isotropic ac 2D Drude conductivity of the form

$$\sigma_{2D} = \frac{n_{2D}e^2}{j\omega m^* \left(1 + \frac{1}{j\omega\tau}\right)}, \quad (2)$$

where e is the electron charge, m^* is the effective electron mass and ω is the angular frequency. The paper also uses the full system of Maxwell's equations, which then dictate the boundary conditions.

We solved the equations using the RF module of the COMSOL Multiphysics® numerical package. The 2DES was modelled using a surface current density defined by (2). The ohmic contacts, the coplanar waveguides, and the gate were modelled as perfect conductors. The whole structure was enclosed in a bounding box with dimensions $223 \mu\text{m} \times 100 \mu\text{m} \times 60 \mu\text{m}$. Two sides of the bounding box were used as excitation and detection ports, while the other sides were perfect electric conductors. The two outer (ground) conductors of the coplanar waveguides were connected to a perfectly conducting box along the length of the structure. This ensured that the even coplanar mode was excited, which was found to couple well to plasmons in the experiments (rather than the slot-line mode, which did not) [7]. The waveguide sections to the both sides of the 2DES were $75 \mu\text{m}$ long.

3. Comparison with experiments: gate-modulation signals

In the experiments, picosecond current pulses from a photoconductive switch were injected into one of the coplanar waveguides. Figure 2 shows the time-domain profile and the power spectrum of the input pulses. They then passed through the 2DES and coupled into the waveguide at the other side of the 2DES. This waveguide was connected to a second switch, where the transmitted pulses were detected. To increase the signal-to-noise ratio of the detected signals, a gate-modulation technique was used. The gate voltage was periodically modulated by a weak signal around a stationary value, which allowed Wu *et al* to employ lock-in detection. As a result, the detected signals were proportional to the absolute value of the derivative of the transmission coefficient with respect to the gate voltage. Figure 3(a) shows, as a colour plot, the experimentally measured signals in the frequency range 100–400 GHz and for a range of gate voltages. The lines superimposed on the plot show the positions of the resonances calculated by a 2D mode-matching technique [24] as reported previously in [25].

In the simulations, we excite the even mode in the left coplanar waveguide at a single frequency, calculate its transmission to the waveguide on the opposite side, and then repeat the calculation for a range of frequencies and electron densities. The simulations are performed in the frequency domains with the same excitation power at every frequency.

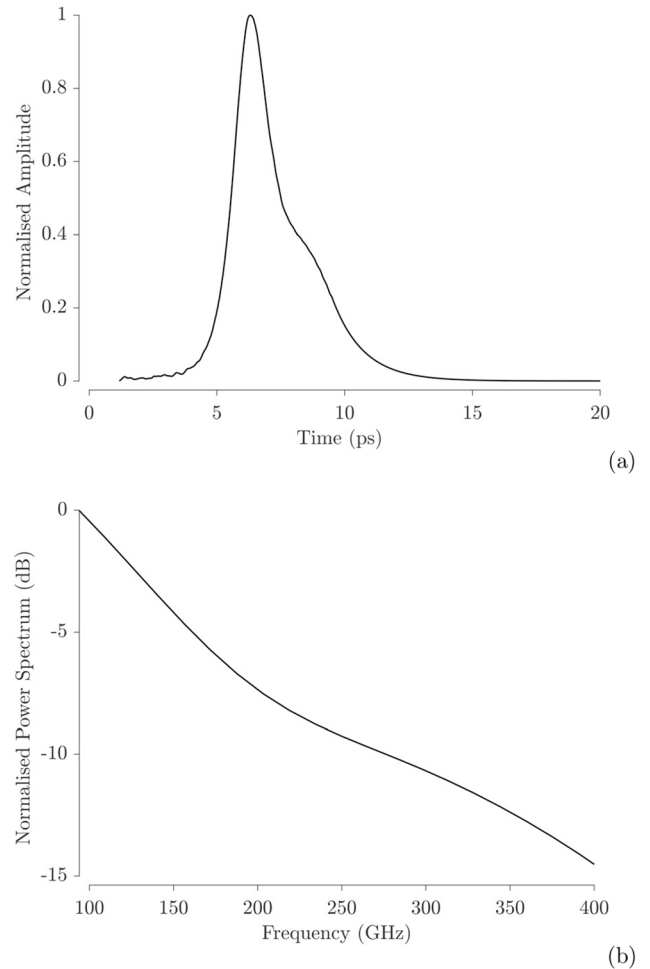


Figure 2. (a) Experimental time-domain input signals and (b) their frequency spectrum.

The experiments, however, excitation power effectively varied with frequency owing to the limited bandwidth of the photoconductive switch used for signal excitation (see figure 2). To allow direct comparison between the simulations and the experiments, we therefore scale the simulation results assuming an exponential decay of the excitation power with the frequency. We then calculate, using (1), the derivative of the transmission with the gate voltage.

Figure 3(b) shows the simulated gate-modulation signals for $\tau = 33$ ps, the value obtained from dc conductivity measurements. The simulated resonances are clearly narrower than the experimentally observed ones, indicating higher losses in the experiment than predicted from the dc value of the scattering time. Such reduction of the quality factors of the experimental terahertz resonances was observed in a number of other experiments that used different 2DES geometries and excitation and detection techniques. For example, Popov *et al* [26] found that the value of τ required to fit the absorption measurements in a grid-gated field-effect transistor was lower than the value predicted from the dc conductivity by roughly an order of magnitude. El Fatimy *et al* [27] reported that a plasmon resonance in a high-electron-mobility transistors measured experimentally had a quality factor of three, lower than the value of 13 expected from the measurements of the dc

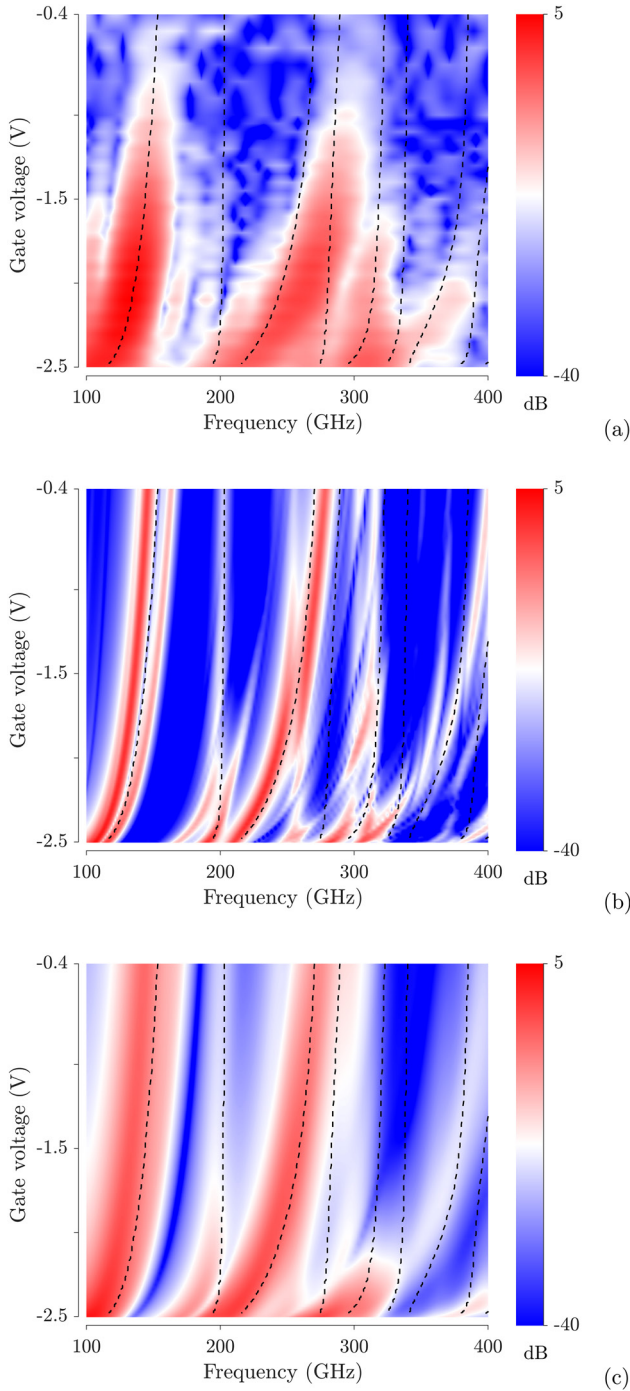


Figure 3. (a) Measured gate-modulation signals (data taken from [7]), compared with models in (b) and (c) where $\tau = 33$ ps and $\tau = 7$ ps, respectively. The lower value of τ provides better agreement with the experiment. The dashed lines show position of the plasmon resonances calculated by a 2D modal technique.

mobility. A number of explanations of the apparent reduction of the value of τ were proposed, such as different relaxation mechanisms involved at dc and the THz frequencies [28], ballistic transport and viscosity [27], leakage of gated plasmons into ungated regions, and oblique modes [29]. No explanation appears so far to have gained wide acceptance. We note, however, that our 3D model directly takes into account the interaction of plasmons in the gated and ungated regions as well

as the plasmon field distribution both along and across the device, and so it is unlikely that plasmon leakage and oblique modes are responsible for the difference between figures 3(a) and (b). Following other authors, we have, therefore, decided to treat τ as a phenomenological parameter, and have repeated the calculations for a number of lower values of τ . We found the best agreement between the experiments and the simulations for $\tau = 7$ ps, as shown in figure 3(c).

Three strong features can be seen both in the theoretical and experimental plots. The first one starts at around 100 GHz for the lowest value of the gate voltage. The second starts at 200 GHz. The third lies around 300 GHz, and is strong only for low values of the gate voltage. The experimental features are shifted to the higher frequencies compared to the theoretical ones. A possible reason for the shift is the approximate nature of (1) that was used to estimate the gate voltage from the theoretical values of the concentration. In the experiments, the gate voltage was measured directly. The maximum amplitudes of the experimental and modelled signals decrease with increasing frequency and with decreasing gate voltage. There are, however, differences in the relationships between the amplitudes of the peaks between the experiment and the simulations. It may be due to the complex shape of the excitation spectrum, which was not fully reproduced in the simulations.

4. Beyond experiment: transmission, reflection, absorption and field profiles

The use of the gate-modulation technique in the experiments was dictated by the need to increase the signal-to-noise ratio and eliminate direct cross-talk between the components on either side of the 2DES. In addition, the picosecond pulses used in the experiments delivered less power at higher frequencies, leading to weaker plasmon excitation.

On the other hand, numerical simulations are free from these constraints, allowing us to analyse the device across a wide parameter space. The colour plot in figure 4(a) shows the simulated transmission (S_{21}) coefficient for $\tau = 7$ ps (as before, the dashed lines are the resonances calculated by the 2D model). More resonances can now be seen than in the gate-modulation plot of figure 3(c). This is because the resonances that depend weakly on the gated electron density are no longer suppressed, and the excitation amplitude is kept constant at all frequencies.

Figure 4(b) shows the transmission (S_{21} , black line) at a single value of the gate voltage, $V_g = -2$ V. It also shows the reflection (S_{11}) and the absorption coefficients (blue and red lines), the later calculated as $1 - |S_{21}|^2 - |S_{11}|^2$. The reflection and absorption of the signal dominate, and the transmitted signal does not exceed -25 dB. The transmission plot shows five resonances at 126, 192, 249, 300, and 358 GHz. To explain their nature, figure 5 shows the longitudinal (x -) component of the electric field, first, as contour plots in the plane of the 2DES (left column) and, second, across the middle of the 2DES (right column).

At the lowest-frequency resonance, only the gated section of the 2DES is excited strongly and evenly across the

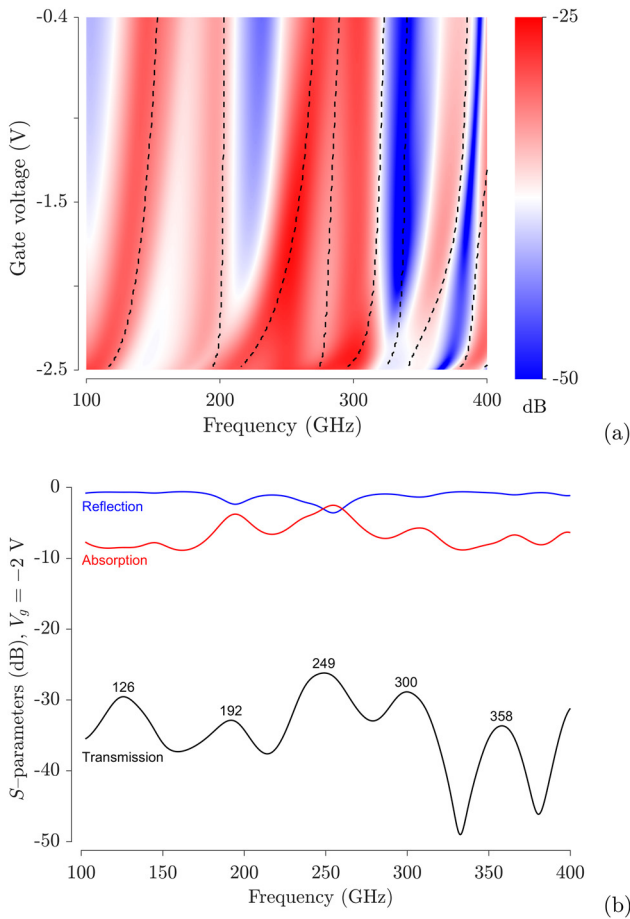


Figure 4. (a) Modelled true transmission for a range of gate voltages and (b) transmission, reflection and absorption at a gate voltage of -2 V in the device. The absorption and reflection dominate, and the transmission does not exceed -25 dB.

width of the 2DES (y -direction). It has a single peak along the length (x -direction) of the gated section, which fits roughly a half of a plasmon wavelength. This is, therefore, the first longitudinal gated-section resonance, and its position agrees well with the 2D calculation shown by dashed lines in figure 4(a).

At the next resonance, the longer (left-hand side) ungated section of the 2DES is excited in addition to the gated section. In the ungated section, the field maximum and minimum are reached at the opposite ends, and the field has a distorted half-wavelength pattern. The excitation amplitudes are higher at the 2DES edges, suggesting excitation of edge plasmons. The field in the gated portion of the 2DES is non-uniform across the width of the 2DES, showing both longitudinal and transverse plasmon excitation. The resonance position agrees well with the 2D calculation (see dashed line in figure 4(a)) which suggests that this resonance corresponds to the first-order longitudinal resonance of the long section of the 2DES.

The third resonance, at 249 GHz, shows strong excitation of both the gated and the long ungated sections, each fitting around one plasmon wavelength. Even though the edges of the ungated section are also excited, it appears to be a predominantly a longitudinal resonance that is a result of an interaction between the gated and the long ungated sections. The nature

of the resonance is confirmed, again, by the good agreement with the 2D model seen from figure 4(a).

The fields of the final two resonances are strongly non-uniform across the width of the different 2DES sections. The gated 2DES shows both longitudinal and transverse plasmon excitation, with multiple field minima and maxima along the x - and y -directions. The long and short ungated 2DESs are excited strongly at the edges. As can be expected, the 2D calculations fail to predict the position of these two resonances.

5. Comparison with experiments: magnetoplasmons

Using the same device and technique, Wu *et al* detected magnetoplasmon resonances in a magnetic field applied perpendicular to the plane of the 2DES [13]. The colour plot in figure 6(a) shows the measured gate-modulation signals. The gate voltage was -2 V, and the magnetic field varied between 0 and 0.4 T. The dashed black lines show the position of 2D resonances found by the mode-matching technique. The red line is the cyclotron resonance.

In the presence of a static magnetic field B_0 pointing in the positive z -direction, the 2D Drude conductivity becomes anisotropic. The current density, \mathbf{J} , can then be expressed as

$$\begin{bmatrix} J_x \\ J_y \end{bmatrix} = \begin{bmatrix} env_x \\ env_y \end{bmatrix} = \begin{bmatrix} \sigma_{xx} & \sigma_{xy} \\ \sigma_{yx} & \sigma_{yy} \end{bmatrix} \begin{bmatrix} E_x \\ E_y \end{bmatrix} \quad (3)$$

where

$$\sigma_{xx} = \sigma_{yy} = \frac{e^2 n_{2D}}{m^*} \frac{(j\omega + \frac{1}{\tau})}{(j\omega + \frac{1}{\tau})^2 + \omega_c^2} \quad (4)$$

$$\sigma_{xy} = -\sigma_{yx} = \frac{e^2 n_{2D}}{m^*} \frac{\omega_c}{(j\omega + \frac{1}{\tau})^2 + \omega_c^2} \quad (5)$$

and $\omega_c = eB_0/m^*$ is the cyclotron frequency.

Figure 6(b) shows the gate-modulation signals simulated using (3)–(5). The qualitative agreement with the experiment is good for the features lying below 300 GHz. As before, the difference in the relative strength of the measured and simulated resonances can be attributed to the spectrum of the excitation pulses. Some of the resonances modelled above 300 GHz do not show in the measurements, possibly because the excitation signals were weak. To the right of the cyclotron line, the simulations predict a strong signal but only a faint feature can be seen in the measurements.

While figures 6(a) and (b) show the gate-modulation signals, figure 7 shows the simulated true transmission coefficient. The maximum transmission does not exceed -25 dB for all values of the magnetic field. The behaviour of the lowest resonance with the magnetic field agrees well with the prediction of the 2D model. The next two resonances agree well with the 2D model at low magnetic field. They do not follow, however, the parabolic behaviour of the 2D curves, and it leads to a discrepancy between the 3D simulation and the 2D model at higher fields. As can be expected from the

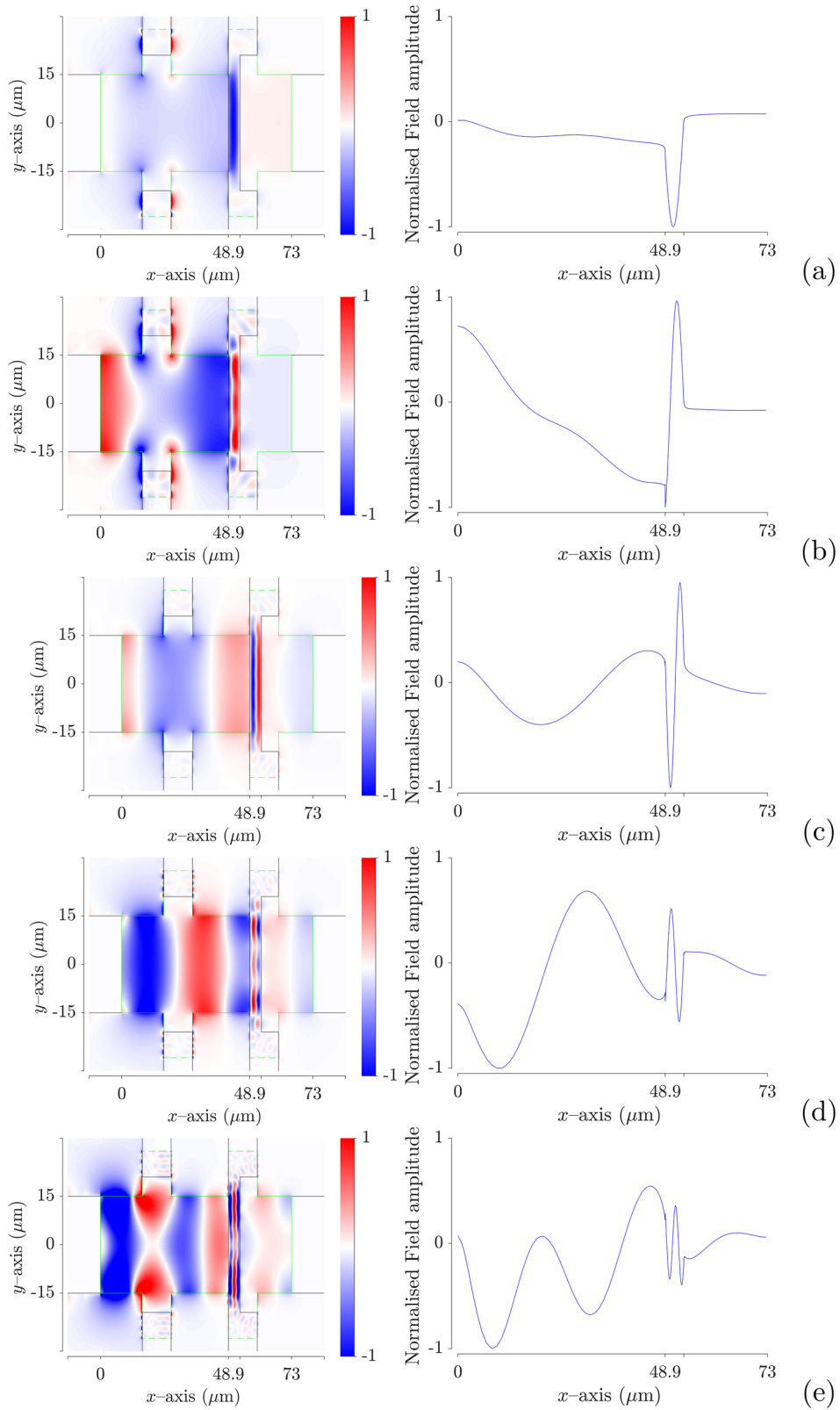


Figure 5. Distributions of the longitudinal component of the electric field in the plane of the 2DES. The frequencies correspond to the transmission peaks in figure 4. The left column presents the top view, the right column presents the field calculated along a line across the middle of the 2DES. The first three resonances appear to be predominantly longitudinal excitations; the last two-resonances show transverse excitations and excitations at the edges of the 2DES.

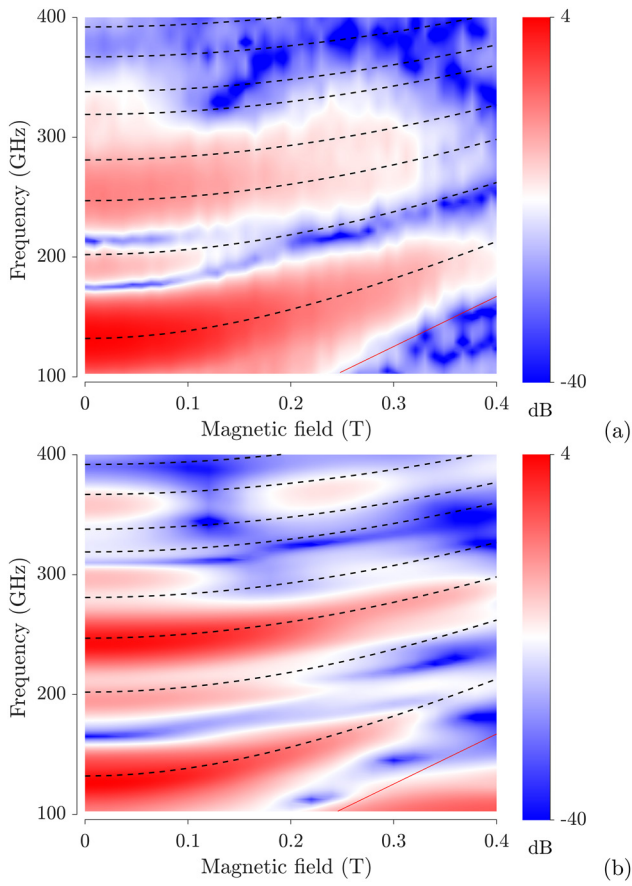


Figure 6. (a) Measured (data taken from [13]) and (b) simulated gate-modulation signals for magneto-plasmons. Theory and experiment agree for features between 100 and 300 GHz.

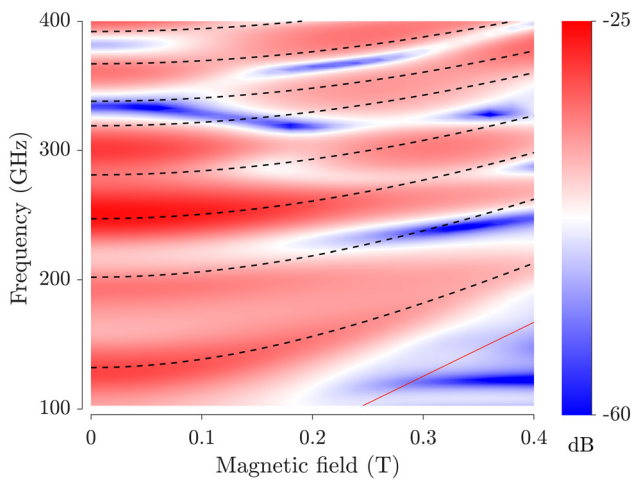


Figure 7. Simulated true transmission for the same structure as in figure 6. The dashed lines show positions of the resonances predicted by the 2D modal technique.

results for zero magnetic field discussed above, the full-wave 3D simulations and the 2D model disagree in their predictions of the resonance positions. We attribute this disagreement to the excitation of edge plasmons and of transverse plasmons (with non-trivial component of the wavenumber in

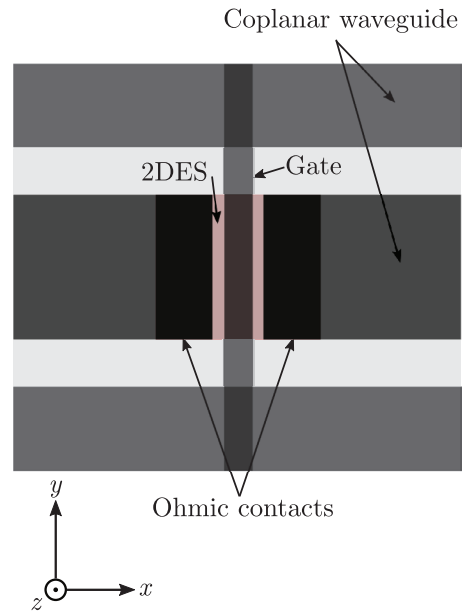


Figure 8. Top view of the device with improved characteristics. A shorter overall length reduces absorption, and connecting the gate and the ground planes of the coplanar waveguides provides better coupling between the 2DES and the waveguides.

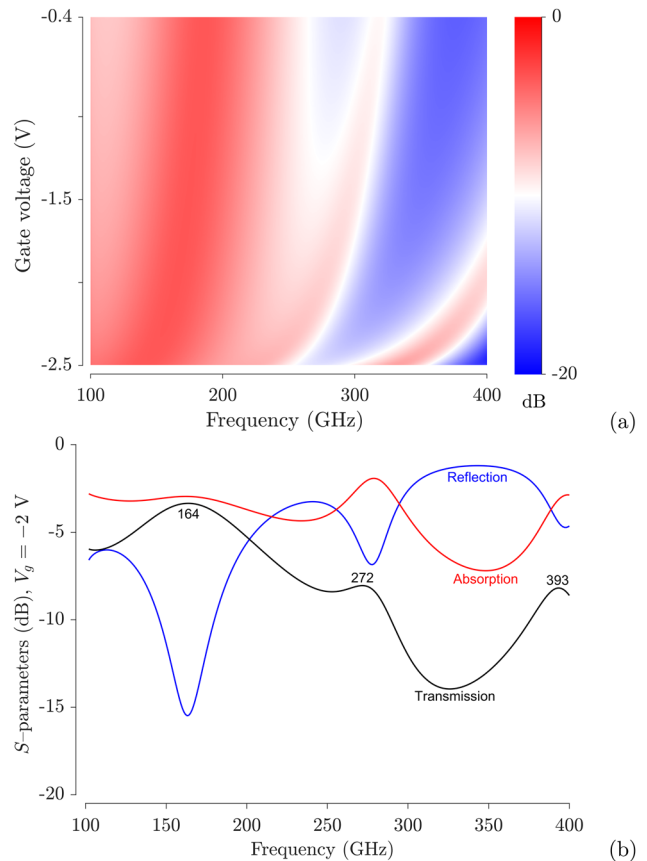


Figure 9. Simulated transmission (a) as a function of gate voltages, and (b) the transmission, reflection, and absorption characteristics at a gate voltage of -2V for the device of figure 8. At 164 GHz, the transmission is around -3 dB , and the reflection is below -15 dB .

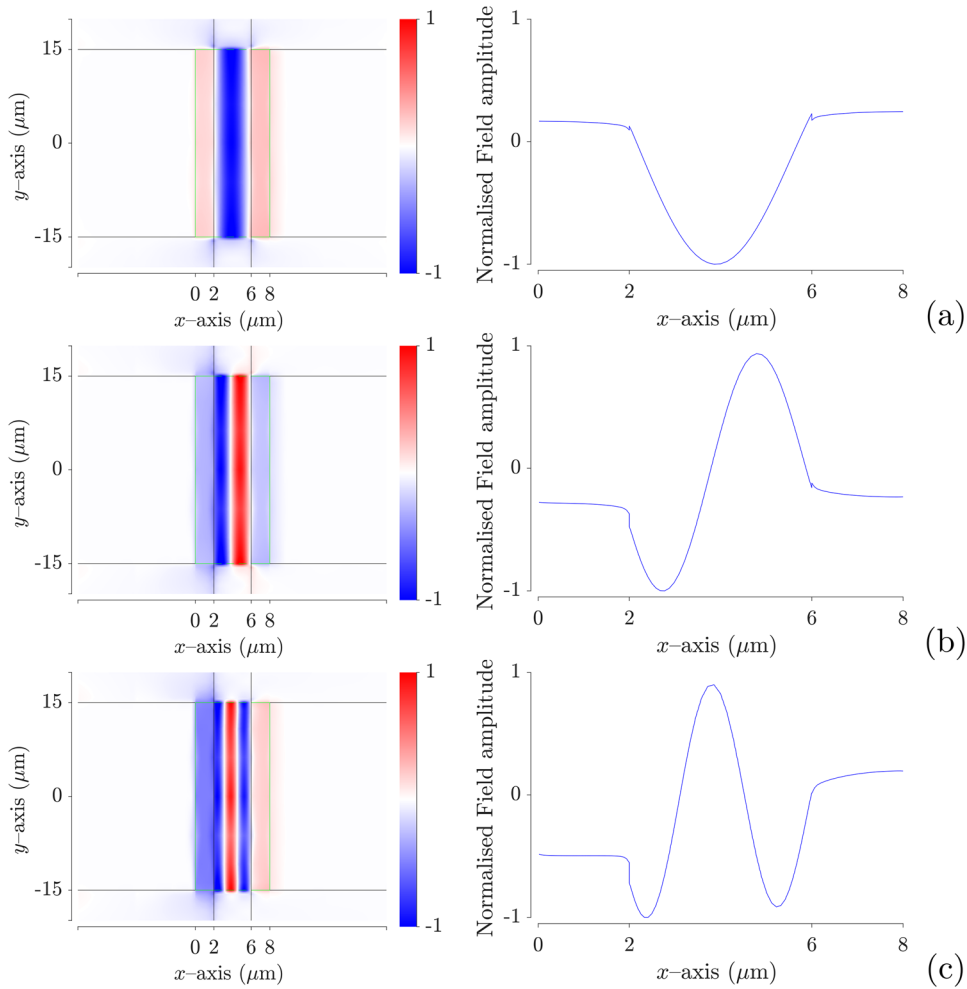


Figure 10. Longitudinal component of the electric field on the 2DES at the three transmission peaks shown in figure 9. The left column presents the top view, the right column presents the field calculated along a line across the middle of the 2DES. At all frequencies, longitudinal plasmons are excited.

the y -direction), both of which are not taken into account by the 2D model.

6. Improving device performance

The simulated transmission for the experimental device did not exceed 25 dB, as shown in figures 4 and 7. Such a low value is due to two factors: high plasmon absorption in the 2DES, and high signal reflection between the 2DES and the coplanar waveguides (figure 4(b)). The plasmon loss could be reduced by shortening the length of the 2DES. The high reflection can be attributed to the dissimilar field distributions in the 2DES and the coplanar waveguides. The even mode supported by the coplanar waveguide is a quasi-TEM mode whose field is concentrated in the gaps between the centre and the ground conductors [30]. On the other hand, plasmons are TM modes whose field is concentrated around the 2DES. Rearranging the waveguide electrodes to create high electric field along the 2DES is, therefore, likely to improve the coupling. It can be done by connecting the gate and the ground electrodes via a capacitor (which will decouple the gate and the ground at dc allowing voltages to be applied to the gate).

A possible device is shown schematically in figure 8. The length of the gated section here is $4\ \mu\text{m}$, and the ungated sections have been both reduced to $2\ \mu\text{m}$. The device width remains $30\ \mu\text{m}$. Figure 9(a) shows the simulated transmission for a range of voltages, and figure 9(b) shows the transmission, reflection and absorption for the gate voltage of -2V . Improvements can be seen upon comparing figure 9 for the new device to figure 4 for the original experimental device. The maximum transmission has increased by over 20 dB for the peak at 165 GHz. The reflection has also decreased by a similar amount. The observed three resonances correspond to the excitation of the longitudinal gated plasmons, as can be seen from the field distributions shown in figure 10 for $V_g = -2\text{V}$ at 164, 272 and 393 GHz. The peak frequencies are close to the three lowest resonant frequencies of longitudinal gated plasmons (144, 279, and 407 GHz) assuming an integer number of plasmon wavelengths in the gated section.

7. Conclusions

A full-wave 3D model of the experimental devices showed agreement with the experimental results obtained by

gate-modulation, both for plasmons and magnetoplasmons. We used this model to analyse device characteristics that could not be directly measured in experiments, such as the true transmission, reflection, and absorption, as well as to study the field distributions at the transmission maxima. We also compared the predictions of the fully 3D model with a 2D model based on modal expansions. While the frequencies of some plasmon resonances could be explained equally well by both approaches, the full-wave simulations showed additional resonances that we attribute to plasmon excitation across and at the edges of the device. Our calculations predict the transmission in the experimental devices to be below -25 dB, in part due to the high plasmon absorption, and in part due to high reflection. By reducing the length of the ungated sections and modifying the coupling geometry between the 2DES and the coplanar waveguides, we presented a device in which the maximum transmission increased by 20 dB.

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